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<b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b> <i>(use as many sheets as necessary)</i>				Application Number	10/821,188
				Filing Date	July 15, 2003
				First Named Inventor	Chien-Wei LI
				Art Unit	1765
				Examiner Name	Karl E. Group
				Attorney Docket Number	H0005038-3002
Sheet	1	of	1		

**U.S. PATENT DOCUMENTS**

Examiner Initials*	Cite No.*	Document Number	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number - Kind Code <sup>2</sup> (if Known)			
6		US-4,234,343	11/16/1980	Andersson	
6		US-4,401,788	08/30/1983	Morgan	
~		US-5,219,600	06/15/1993	Yoshida et al.	
C		US-5,523,287	06/04/1996	Tanaka et al.	
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		US-			

## FOREIGN PATENT DOCUMENTS

## **NON PATENT LITERATURE DOCUMENTS**

Examiner Initials*	Cas No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T <sup>2</sup>
E1		GIUSEPPE PEZZOTTI and HANS-JOACHIM KLEEBE, Effect of Residual Microstresses at Crystalline Multigrain Junctions on the Toughness of Silicon Nitride, Journal of the European Ceramic Society, Elsevier Science Publishers, Barking, Essex, GB, vol. 19, no. 4, April 1999, PP. 451-455.	
L		HEON-JIN CHOI, JUNE-GUNN LEE and YOUNG-WOOK KIM, High Temperature Strength and Oxidation Behaviour of Hot-Pressed Silicon Nitride-Disilicate Ceramics, Journal of Materials Science, Chapman and Hall Ltd., London, GB, vol. 32, no. 7, April 1997, PP. 1937-1942.	

*\*Examiner: Initial if reference considered, whether or not a rejection is in conformance with MPEP 608. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.*

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